

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	diffus\$3 near F near atom\$1 near surface near epi\$6 near substrate	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/05/25 20:54
L2	2	(diffus\$3 near F near atom\$1) and (surface near epi\$6 near substrate)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/05/25 20:56
L3	2	diffus\$3 and (F near atom\$1) and (surface near epi\$6 near substrate)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/05/25 20:56
L4	2	(F near atom\$1) and (surface near epi\$6 near substrate)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/05/25 20:56
S1	0	09/520,959	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 11:57
S2	0	09/520959	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 11:58
S3	1	"09520959"	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 11:59
S4	0	64-047055	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 12:25
S5	381	((silicate adj glass) BPSG) with nitrogen	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 15:09
S6	18	((silicate adj glass) BPSG) with nitrogen) and ((dinitrogen near monoxide) (NO near gas))	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 12:32

S7	5	((silicate adj glass) BPSG) with nitrogen) and ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 12:37
S8	381	((silicate adj glass) BPSG) with \$2nitrogen	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 12:36
S9	7445	((silicate adj glass) BPSG) and \$2nitrogen	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 12:36
S10	73	((silicate adj glass) BPSG) and \$2nitrogen) and ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 14:17
S11	13	("3883889" "3976524" "4621414" "4871689" "4960727" "5004703" "5168343" "5387540" "5593912" "5616401" "5780346" "5966616" "5985735").PN.	USPAT	OR	ON	2004/11/01 12:56
S12	66	\$2nitrogen with heat with ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 15:07
S13	133	\$2nitrogen same heat same ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 14:46
S14	36	nitrogen with (heat near treat\$4) with ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 15:09
S15	206	nitrogen and (heat near treat\$4) and ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 16:30
S16	28	(nitrogen and (heat near treat\$4) and ((dinitrogen near monoxide) N2O)) and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 15:28

S17	26	(nitrogen and (heat near treat\$4) and ((dinitrogen near monoxide) N2O)) and (nitrogen near2 oxide near (layer film))	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 15:14
S18	29	(((SiON) nitrogen oxynitride) and (heat near treat\$4) and ((dinitrogen near monoxide) N2O)) and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 16:29
S19	38	((SiON) nitrogen oxynitride) with (heat near treat\$4) with ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 15:31
S20	217	(((SiON) nitrogen oxynitride) and (heat near treat\$4) and ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 16:28
S21	171	((SiON) nitrogen oxynitride) with (absence near2 hydrogen)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 16:30
S22	0	(((SiON) nitrogen oxynitride) with (absence near2 hydrogen)) and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 10:29
S23	116743	((SiON) nitrogen oxynitride) with hydrogen	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 16:30
S24	1646	(((SiON) nitrogen oxynitride) with hydrogen) and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/01 16:30
S25	8	(((SiON) nitrogen oxynitride) with hydrogen) and ((silicate adj glass) BPSG)) and (heat near treat\$4) and ((dinitrogen near monoxide) N2O)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/04 18:36
S26	5092	((SiON) (nitrogen near2 oxide) oxynitride) with (hydrogen H2)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 11:08

S27	61011	((SiON) (nitrogen near2 oxide) oxynitride) NOT (hydrogen H2)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 10:32
S28	2125	((SiON) (nitrogen near2 oxide) oxynitride) NOT (hydrogen H2)) and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 10:32
S29	199	((SiON) (nitrogen near2 oxide) oxynitride) with (hydrogen H2)) and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 11:09
S30	3	((SiON) (nitrogen near2 oxide) oxynitride) with (hydrogen H2)) and ((silicate adj glass) BPSG)) and (prevent\$3 near2 boron near2 diffus\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 10:40
S31	46	((SiON) (nitrogen near2 oxide) oxynitride) NOT (hydrogen H2)) and (prevent\$3 near2 boron near2 diffus\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 11:05
S32	11	((SiON) (nitrogen near2 oxide) oxynitride) with (hydrogen H2)) and (prevent\$3 near2 boron near2 diffus\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/04 18:32
S33	447	prevent\$3 near2 boron near2 diffus\$3	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 11:08
S34	103	(prevent\$3 near2 boron near2 diffus\$3) and ((SiON) (nitrogen near2 oxide) oxynitride)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 11:09
S35	29	((prevent\$3 near2 boron near2 diffus\$3) and ((SiON) (nitrogen near2 oxide) oxynitride)) and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2004/11/02 11:09
S36	696	((SiON) (nitrogen near2 oxide) oxynitride) with (conduct\$3 near (film layer))	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/04 19:15

S37	148	S36 and ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/04 19:12
S38	63	S37 and (gate near (oxide insulat\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/04 18:37
S39	37	((SiON) (nitrogen near2 oxide) oxynitride) with (conduct\$3 near (film layer)) with ((silicate adj glass) BPSG)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/02/04 19:16